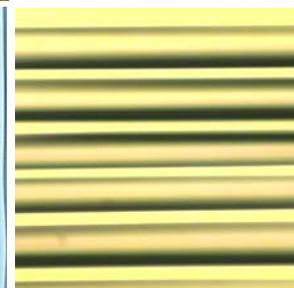
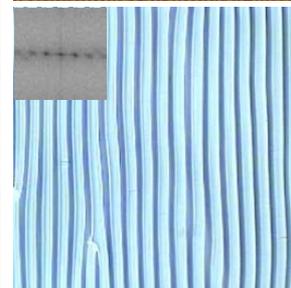
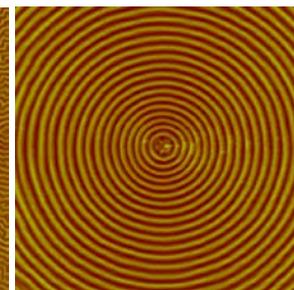
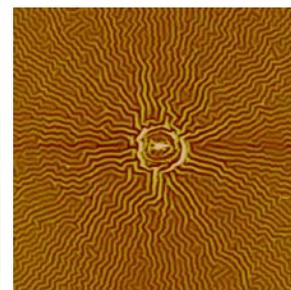
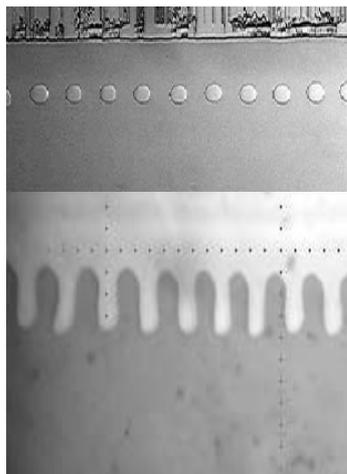


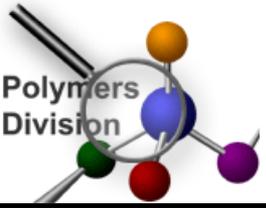
Surface Wrinkling: A Powerful Tool for Measuring Material Properties

Jun Young Chung

Polymers Division
National Institute of Standards and Technology
(NCCM 14 - November 7, 2008)

Instabilities & Self-Patterning by Stress Engineering



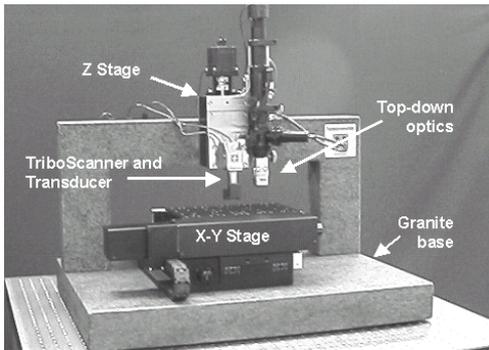
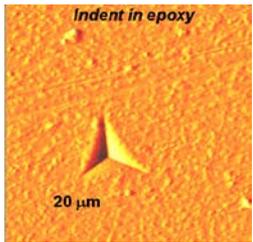


- o Mechanical properties (e.g., modulus, Poisson's ratio, CTE) are critical in many applications.
 - performance and reliability
 - predictive modeling of complex systems

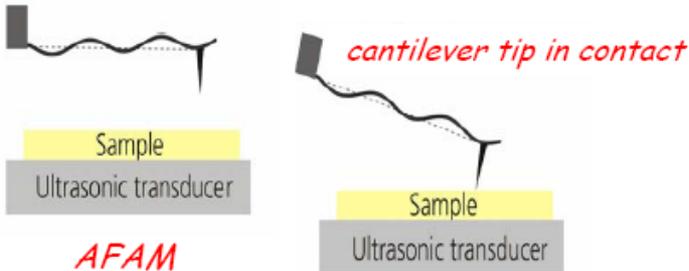
o Measuring mechanical properties of sub-micron (nano) films remains difficult.

Nanomechanics:

Indentation

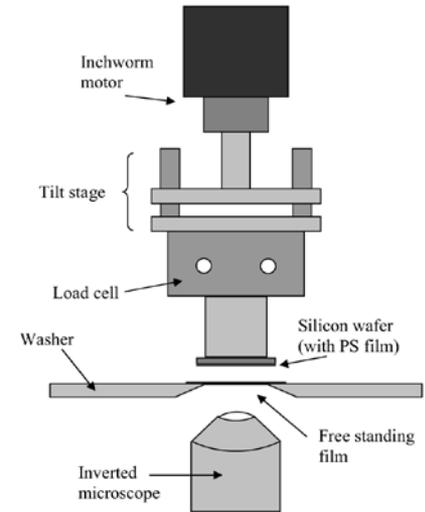
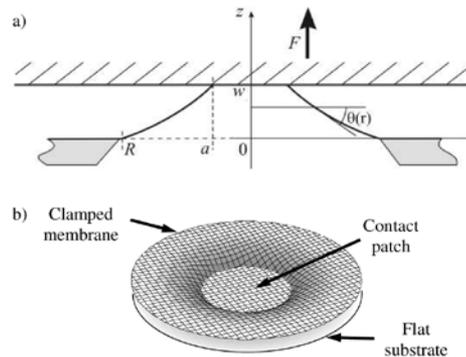


clamped-free AFM cantilever



Rabe et al. *J Vac Sci Technol B* **15** 1506 (1997)
Hurley et al. *J Appl Phys* **94** 2347 (2003)

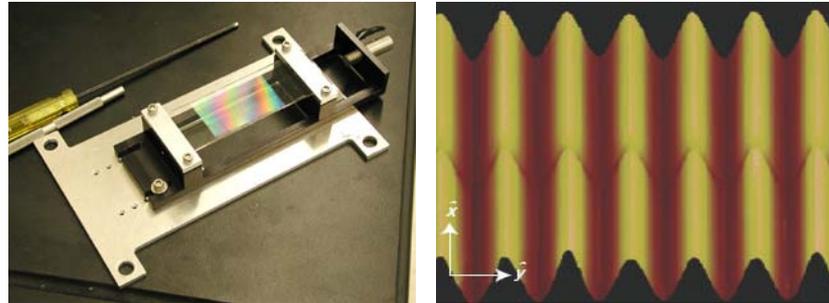
Membrane Punch



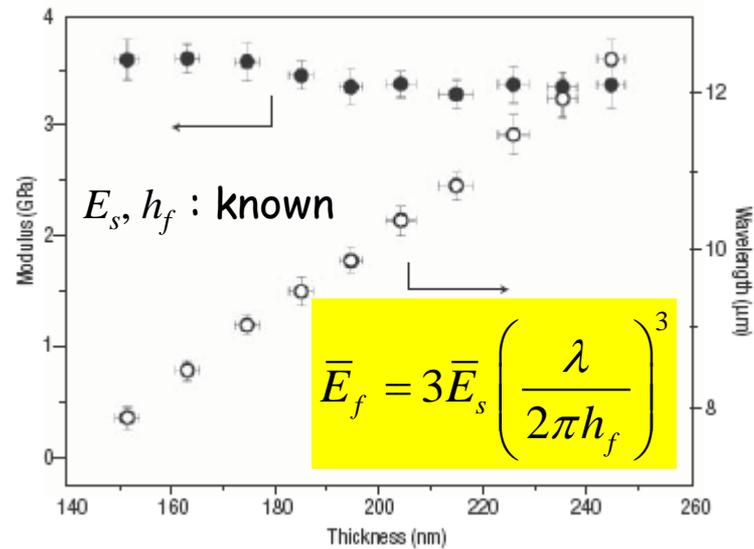
Raegan et al. *Eur. Phys. J. E* **19**, 453-459 (2006)

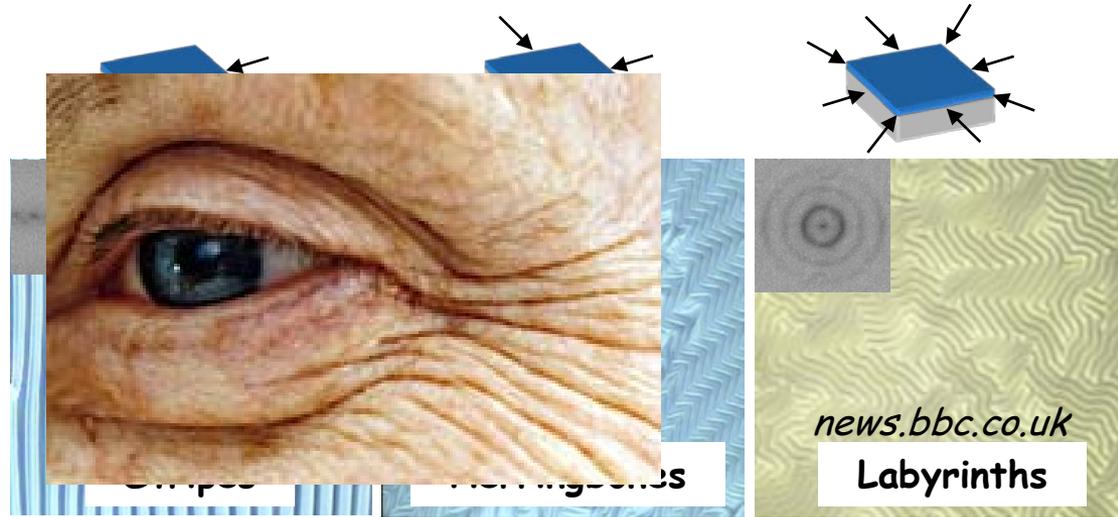
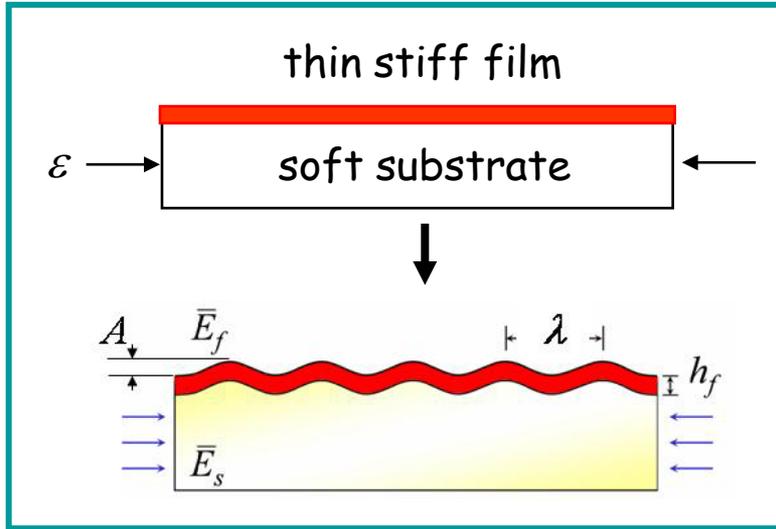
*Challenged by thin (soft) polymers
- substrate effects!*

Young's Modulus Measurements:

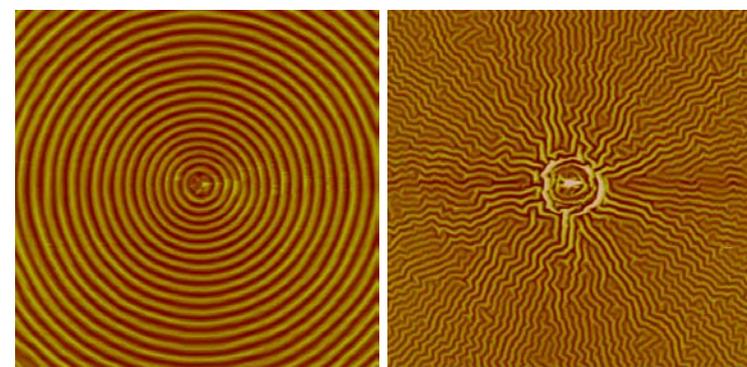


PS Film / PDMS

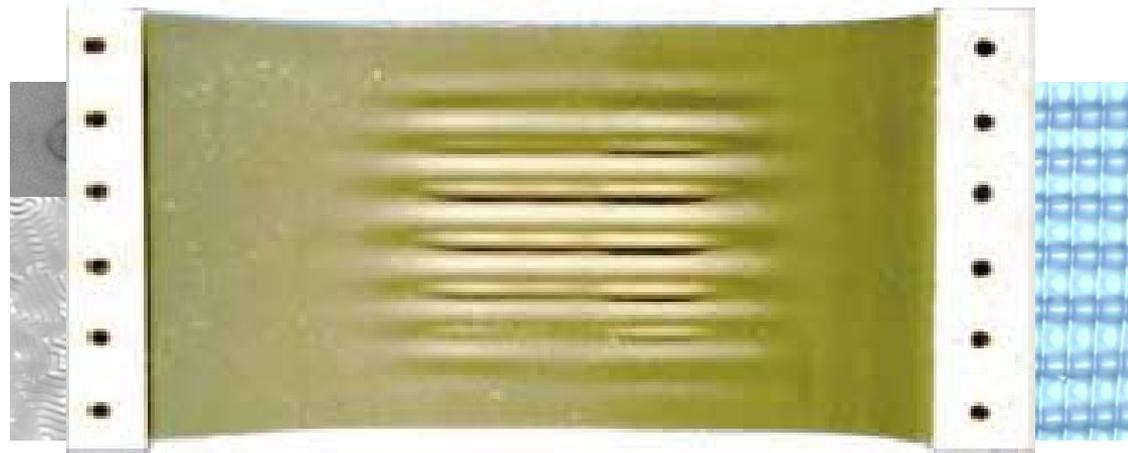




Mechanical Compression



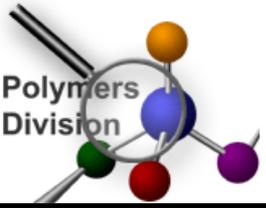
Solvent Swelling through
Initial Defects



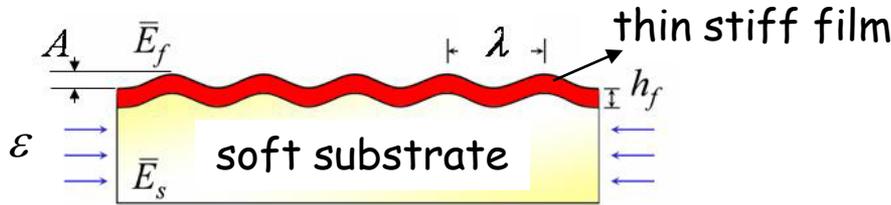
Thermal Contraction

Mechanical
+ Thermal

On Pre-patterned
Substrates



Surface Wrinkling - Mechanics



Governing Equations:

$$\lambda = 2\pi h_f \left(\frac{\bar{E}_f}{3\bar{E}_s} \right)^{1/3}$$

$$A = h_f \left(\frac{\epsilon}{\epsilon_c} - 1 \right)^{1/2}$$

$$\epsilon_c = -\frac{1}{4} \left(\frac{3\bar{E}_s}{\bar{E}_f} \right)^{2/3}$$

$$\bar{E} = E / (1 - \nu^2)$$

$$E_s \ll E_f$$

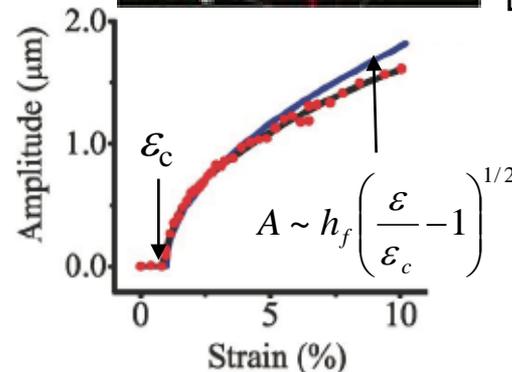
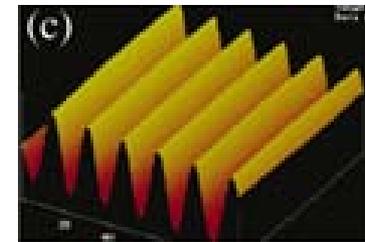
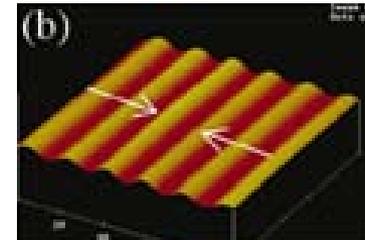
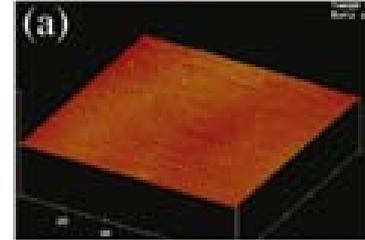
$$h_s \gg h_f$$

- interface must be well-bonded
- materials behave elastically

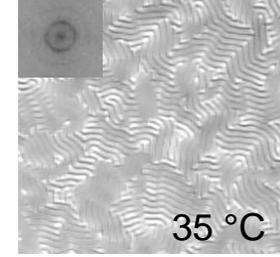
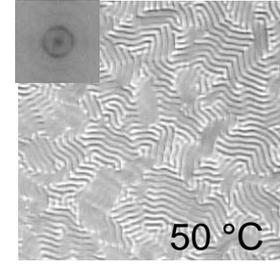
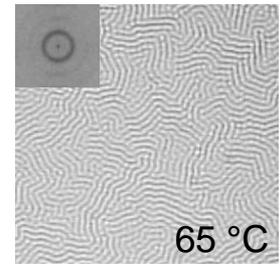
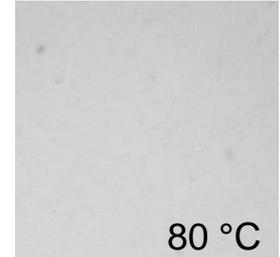
Volynskii et al., *J Mater Sci* (2000), Groenewold, *Phys A* (2001)*, Huang, *J Mech Phys Solids* (2005)

Wrinkling wavelengths are insensitive to strain for low strain levels and wrinkles are reversible.

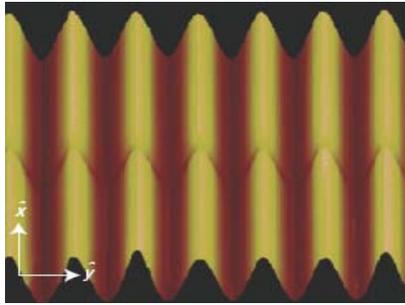
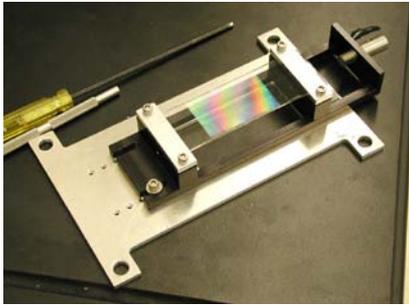
Mechanical (PS Film / PDMS) Thermal



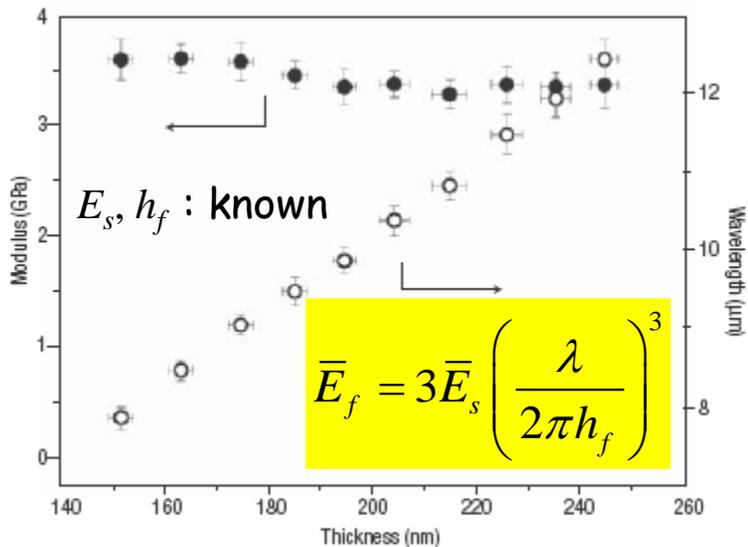
strain increases



Young's Modulus Measurements:

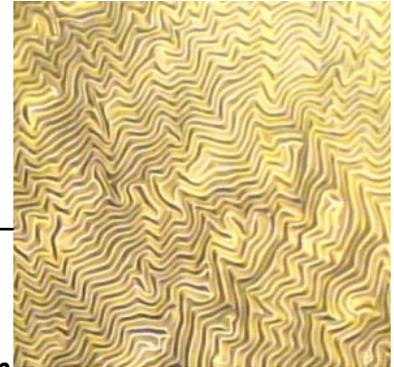
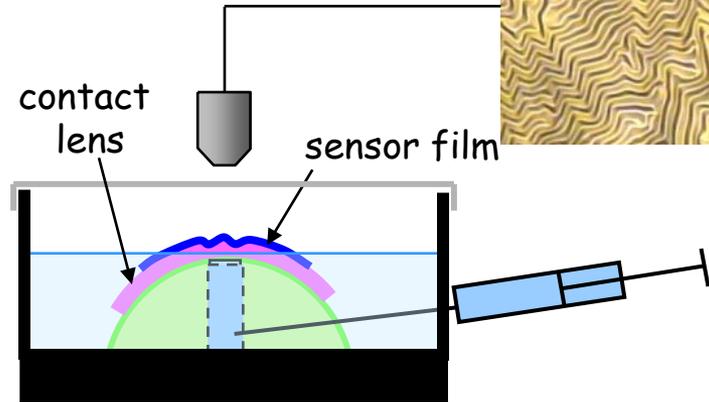


PS Film / PDMS



Stafford et al., *Nature Mater* (2004)

PMMA Film /
Contact Lens



Reverse metrology - Employ a 'sensor' film of known modulus and thickness to report back the substrate modulus:

$$\bar{E}_s = \frac{\bar{E}_f}{3} \left(\frac{\lambda}{2\pi h_f} \right)^{-3}$$

E_f, h_f : known

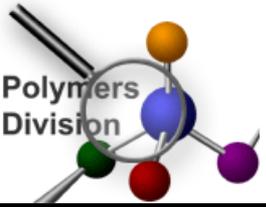
NCMC Focus Project

Vistakon Division

of Johnson & Johnson Vision Care, Inc.

Wilder et al., *Macromolecules* (2006)

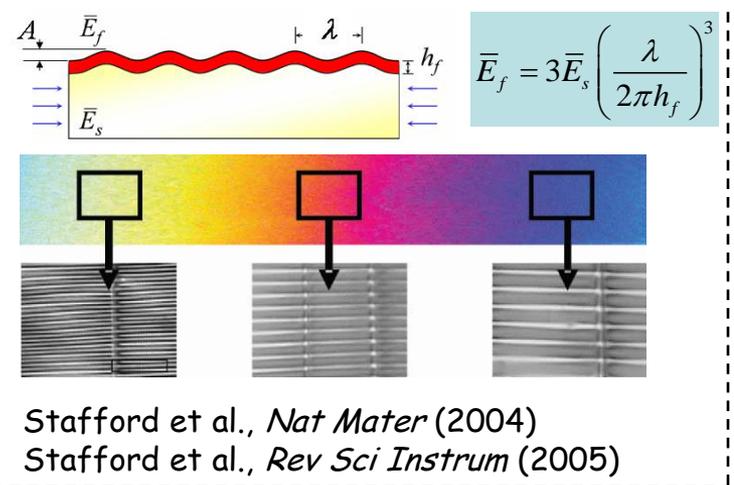
Chastek, Chung, Hopson, Fasolka & Stafford (in progress)



Leveraging Wrinkling Approaches (I)

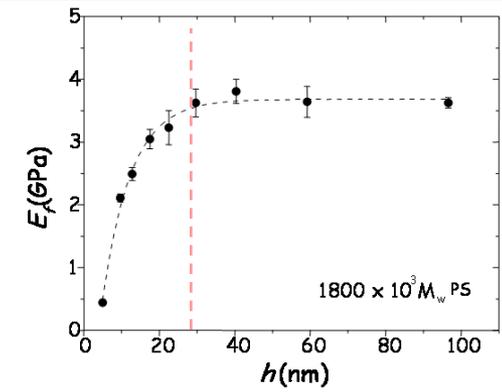
Taking on the challenge of difficult systems:

Wrinkling Approach: Mechanical Modulus across Gradient Polymer Film Libraries



Extend Limit
 →

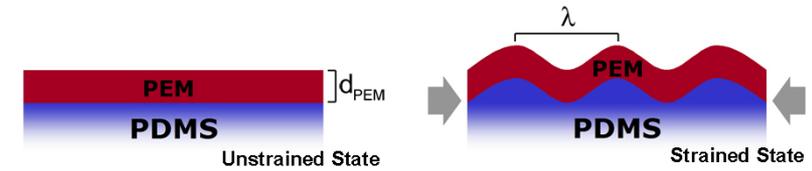
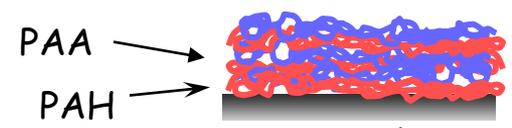
Modulus of ultrathin films (< 100 nm!)



Stafford et al., *Macromolecules* (2006),
 Huang et al. *J Aerospace Eng* (2007)

Polyelectrolyte Multilayer

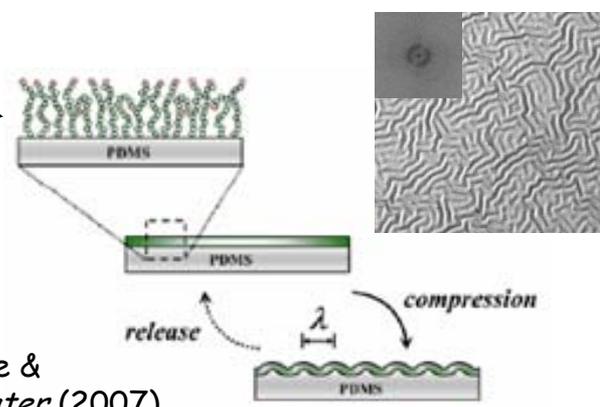
LbL assembly of polyelectrolytes directly on PDMS



Nolte et al., *Macromolecules* (2005) and (2006)
 Nolte, Chung, Walker & Stafford (submitted)

Polymer Brush

Polymer brush layers tethered on PDMS



Huang, Chung, Nolte & Stafford, *Chem Mater* (2007)

Taking on the challenge to perform difficult measurements:

o Thermo-mechanical properties

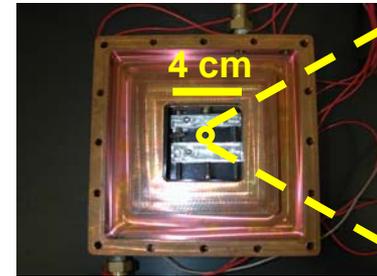
$$\bar{E}_f(T) = 3\bar{E}_s \left(\frac{\lambda(T)}{2\pi h_f} \right)^3$$

o Residual stress

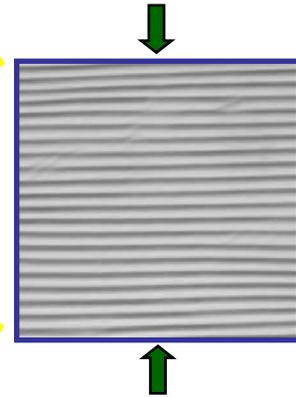
$$\varepsilon_{Theory} = -\frac{1}{4} \left(\frac{3\bar{E}_s}{\bar{E}_f} \right)^{2/3}$$

Access to thermo-mechanical properties

Temperature-Dependent Modulus

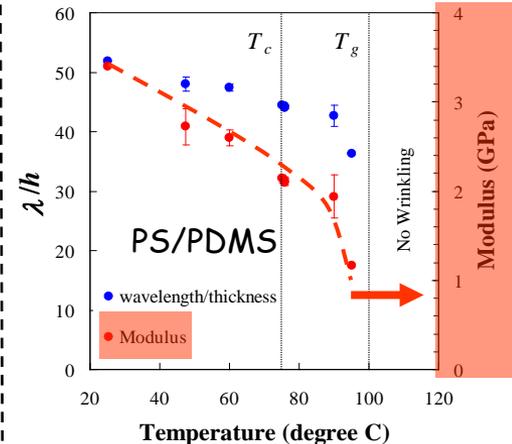
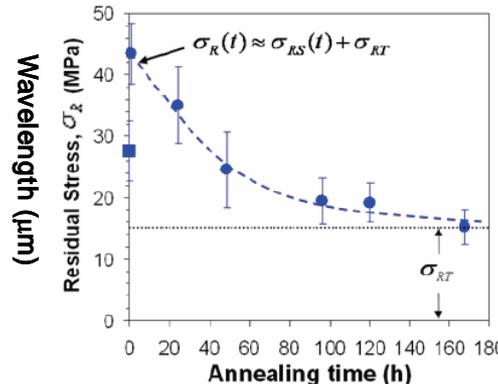
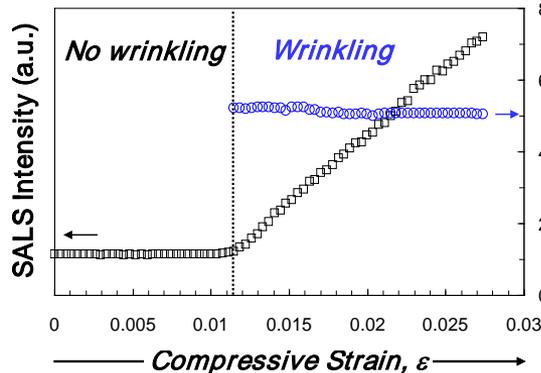
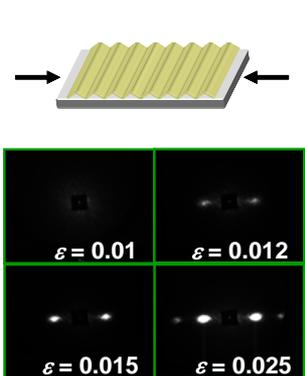


Mechanical compression at an elevated temp.

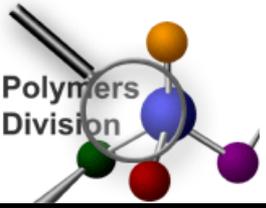


Refine Analysis

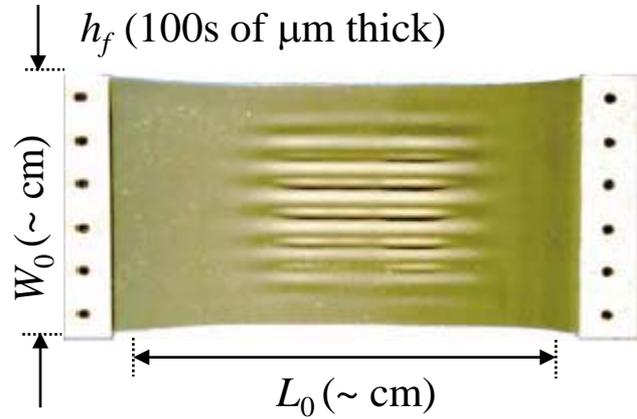
Chung, Chastek, Fasolka, Ro & Stafford (submitted)



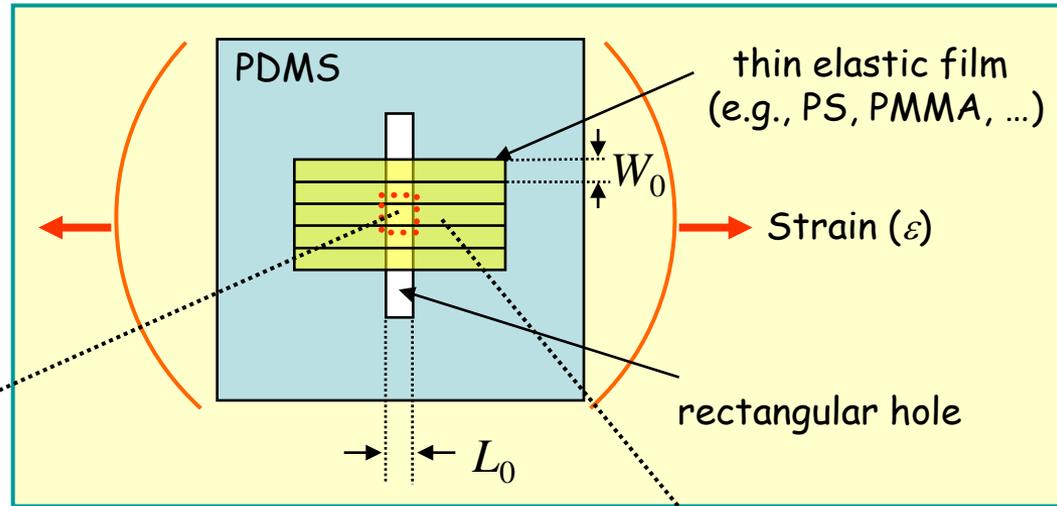
Chung & Stafford (in progress)



Poisson's Ratio Measurement

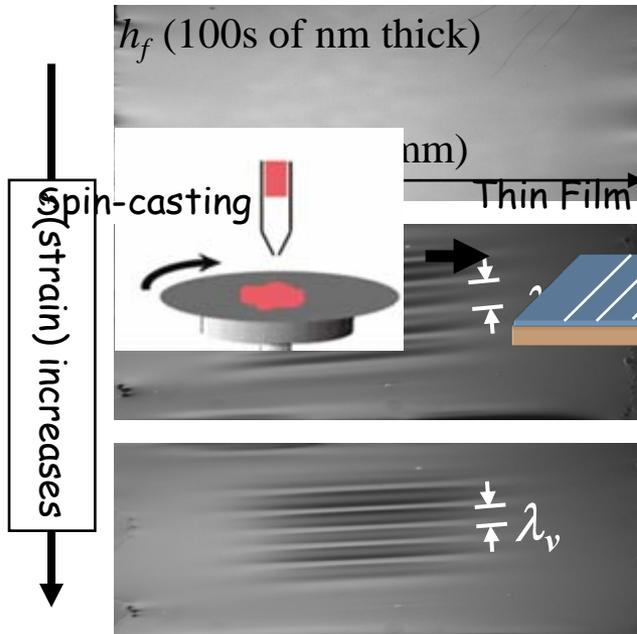


Scale-down



free-standing film

bilayer



Spin-casting (strain) increases

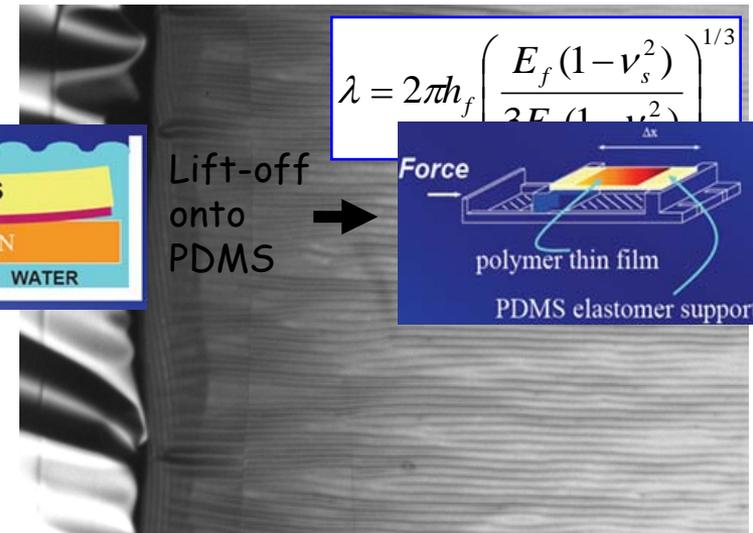
Thin Film Dicing

$W_0 (< \text{mm})$

$$\lambda_v = \left(\frac{4\pi^2 (h_f L_0)^2}{3(1-\nu_f^2)} \right)^{1/4} \epsilon^{1/4}$$

ν_f (Poisson's ratio) is only unknown

Cerda et al., *Nature* (2002) and *PRL* (2003)

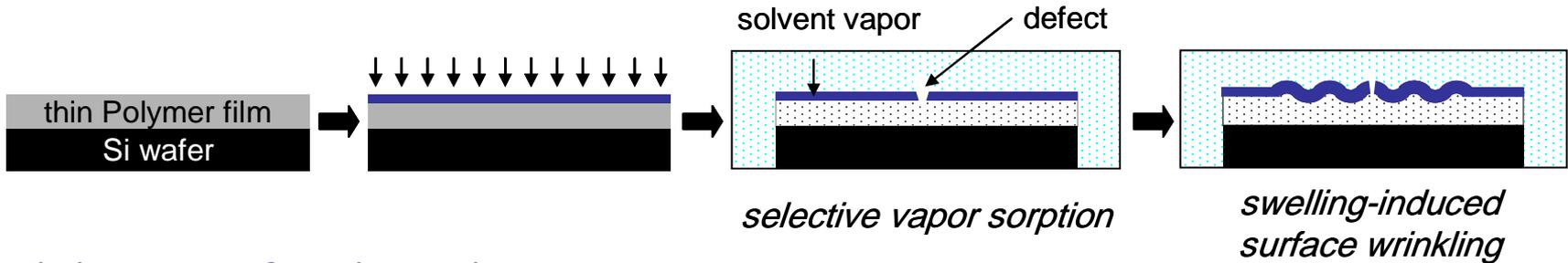


Lift-off onto PDMS

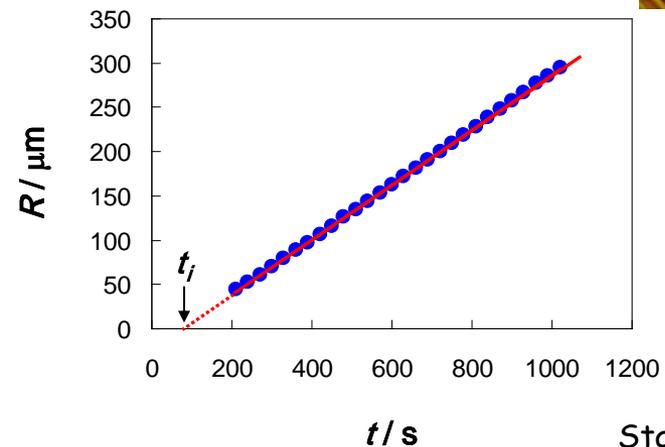
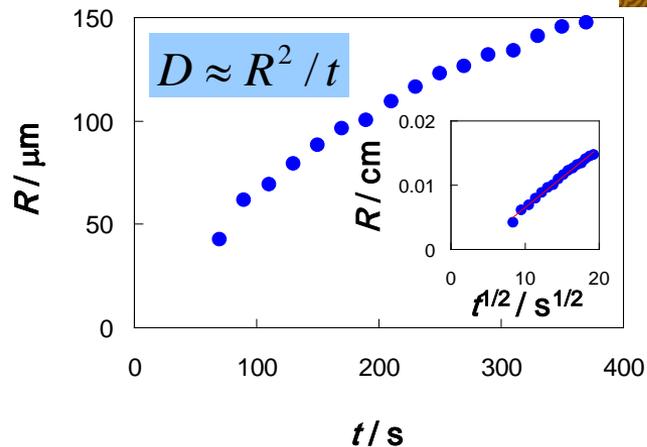
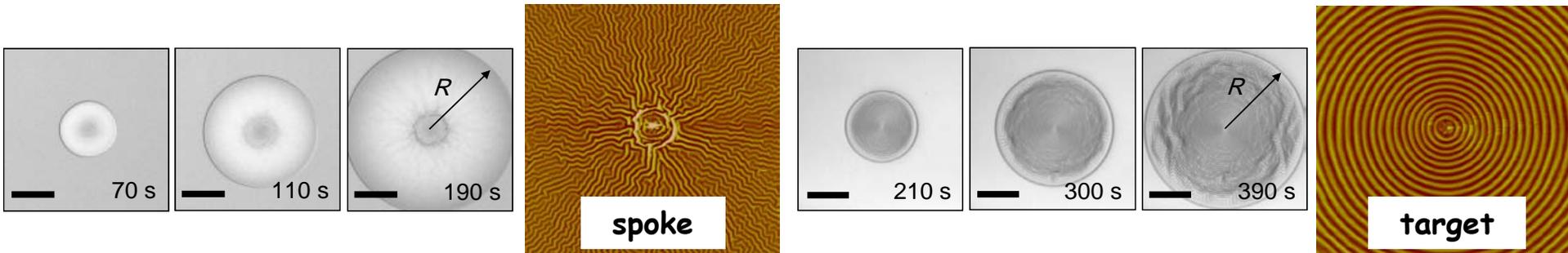
$$\lambda = 2\pi h_f \left(\frac{E_f(1-\nu_s^2)}{2E_s(1-\nu_f^2)} \right)^{1/3}$$

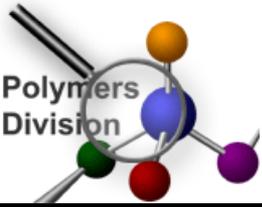
Chung et al., (in progress)

Differential swelling (Defect-mediated wrinkling nucleation and growth)



Growth kinetics of spoke and target patterns

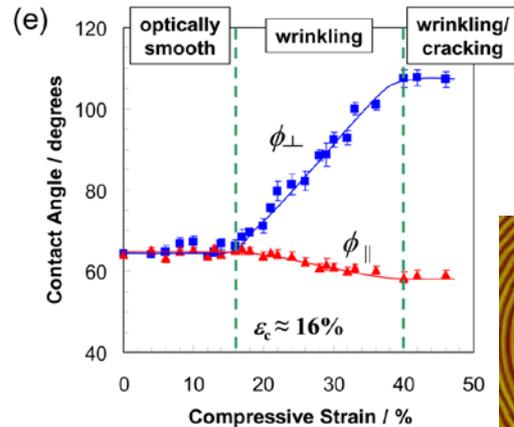
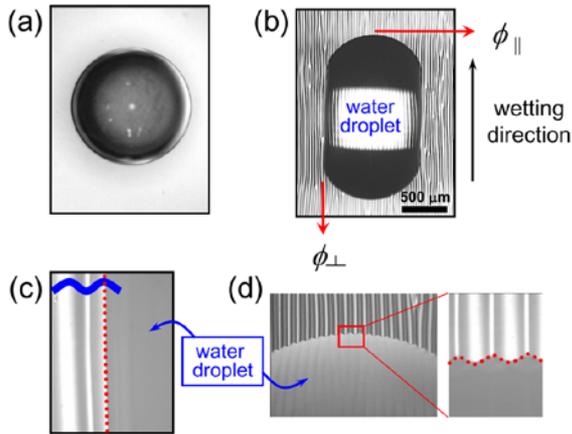




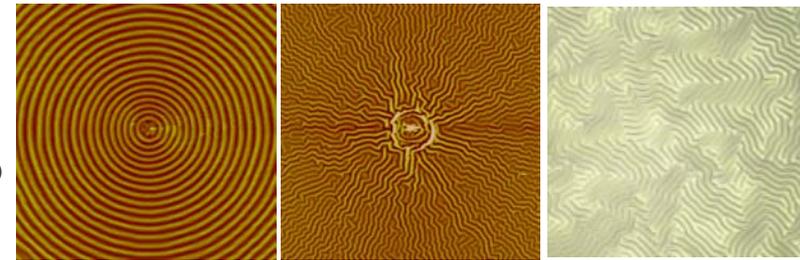
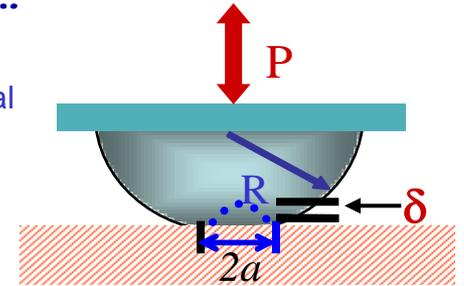
Surface Wrinkling: A Powerful Tool for Measuring Material Properties

- **Elastic Modulus of Thin Films:** glassy polymers (PS and PMMA)
hydrated polymer gels (contact lenses)
polymer brush layers
polyelectrolyte multilayers
- **Thermo-Mechanical Properties:** temperature-dependent modulus
coefficient of thermal expansion
- **Residual Stress:** nanoscale thin spin-cast polymer films
- **Poisson's Ratio:** glassy polymers
apply to low-k dielectric materials (collaboration w/ IBM)
- **Diffusion Coefficient:** glassy polymers

Controlled topography: wettability & adhesion studies, ...



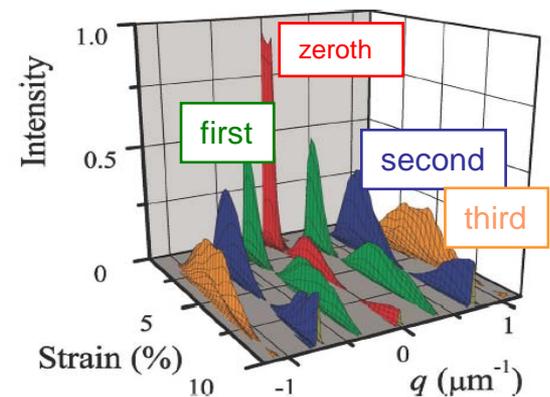
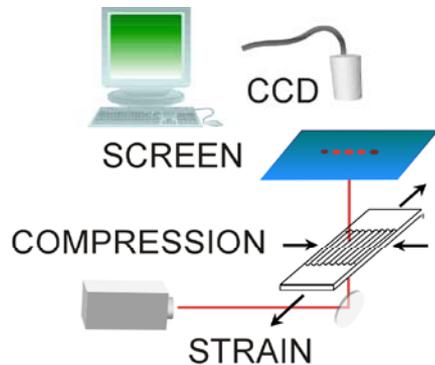
spherical probe



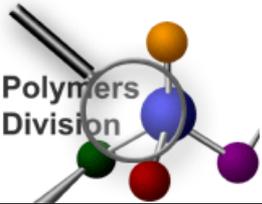
patterned substrate

Chung, Youngblood & Stafford, *Soft Matter* (2007)

Periodic nature of wrinkling: tunable phase grating, microfluidics, ...



Harrison, Stafford, Zhang & Karim, *APL* (2004)



Acknowledgements

Dr. Christopher M. Stafford (NIST)
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Dr. Michael J. Fasolka (NIST)
Prof. David Dillard (Virginia Tech)
Prof. Robert Y. Lochhead (U. Southern Mississippi)

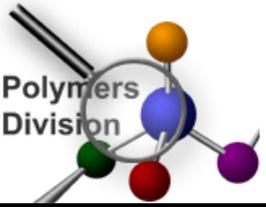
Mentors

Prof. Rui Huang (U. Texas - Austin) for wrinkling mechanics
Prof. Jeffrey P. Youngblood (Purdue U.) for wettability
Dr. Peyton L. Hopson (Vistakon) for contact lenses
Dr. Ho-Cheol Kim (IBM) for low-k materials

**Outside
Collaborators**

Dr. Thomas Q. Chastek for residual stress measurement
Dr. Adam J. Nolte for brush/LbL wrinkling & diffusivity measurement
Dr. Thuy T. Chastek for reverse buckling
Dr. Hyun-Wook Ro for x-ray reflectivity & thin film stress measurement
Dr. Hae-Jeong Lee for low-k materials
Dr. Peter Johnson
Dr. Edwin P. Chan

NIST



Questions?

